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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/052,638	01/23/2002	Hiroshi Komatsu	4805.0185-02	4034
	7590 09/02/2003			-
FINNEGAN, HENDERSON, FARABOW, GARRETT & DUNNER LLP 1300 I STREET, NW			EXAMINER	
			TON, MINH TOAN T	
WASHINGIC	ON, DC 20005		ART UNIT	PAPER NUMBER
			2871	
			DATE MAILED: 09/02/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

	J.	Application No.	Applicant(s)			
Office Action Summary		10/052,638	KOMATSU, HIROSHI			
		Examiner	Art Unit			
	7.	Toan Ton	2871			
Period to	• •					
I H L I - Exter after - If the - If NO - Failu - Any r	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. Insions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. In period for reply specified above is less than thirty (30) days, a reply in period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, epty received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days fill apply and will expire SIX (6) MONTHS from Cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication.			
Status	og patent term aujustment. See 37 CFR 1.704(b).					
1)	Responsive to communication(s) filed on					
2a) <u></u>	This action is FINAL . 2b)⊠ Thi	s action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the ments is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims						
4)⊠ Claim(s) <u>20-50</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>20-50</u> is/are rejected.						
7)	Claim(s) is/are objected to.					
8)□ Applicatio	Claim(s) are subject to restriction and/or on Papers	election requirement.				
9)□ 1	The specification is objected to by the Examiner.					
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
	a)⊠ All b)□ Some * c)□ None of:					
	1. Certified copies of the priority documents have been received.					
2	2. Certified copies of the priority documents have been received in Application No. 09/114,302					
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
	cknowledgment is made of a claim for domestic					
a)	☐ The translation of the foreign language provi	isional application has been rece	ived.			
Attachment(F. 120 6	anu/ULIZI,			
2) Notice 3) Informa	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449) Paper No(s) 4.	4) Interview Summary (5) Notice of Informal Pa 6) Other:	PTO-413) Paper No(s) Itent Application (PTO-152)			
.S. Patent and Trad PTOL-326 (Rev	. 04.04	on Summary	Part of Paper No. 08282003			

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Double Patenting

The nonstatutory double patenting rejection is based on a judicially created doctrine 1. grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See In re Goodman, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); In re Longi, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); In re Van Ornum, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); In re Vogel, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, In re Thorington, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 20-50 are rejected under the judicially created doctrine of obviousness-type 2. double patenting as being unpatentable over claims 1-16 of U.S. Patent No. 6259502. Although the conflicting claims are not identical, they are not patentably distinct from each other because the present and patent claims recite common and overlapping subject matter such as a common bus line over a first substrate; a first insulator over the common bus line; a data electrode over the first insulator, the data electrode at least partially covering the common bus line to form a

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storage capacitor between the data electrode and the common bus line; a second insulator over the data electrode; and a common electrode over the second insulator.

The patent recites in claim 3 the data electrode conductively coupled to the common bus line through a hole in the first and second insulators.

The patent recites in claim 5 the first insulator includes a gate insulator.

The patent recites in claim 7 the second insulator including a passivation layer.

The patent recites in claim 8 a plurality of gate and data bus lines aligned in the first substrate to define a plurality of pixel regions, wherein the common electrode at least partially overlies the data bus lines.

The patent recites in claim 13 the data bus lines including one of a Mo metal layer, Mo/Al/Mo triple metal layers, or Cr/Al/Cr triple metal layers.

The patent recites the alignment layer including of polyimide or polyamide, or polyvinylcinnamate or polysiloxane based materials.

The use of a black matrix (commonly disposed in non-displaying regions) is common and known in the art for advantages such as high contrast and resolution. Therefore, it would have been obvious to one of ordinary skill in the art to employ a black matrix for advantages such as high contrast and resolution.

3. Claims 20-50 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-10 of U.S. Patent No. 6384888. Although the conflicting claims are not identical, they are not patentably distinct from each other because the present and patent claims recite common and overlapping subject matter such as a common

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bus line over a first substrate; a first insulator over the common bus line; a data electrode over

the first insulator, the data electrode at least partially covering the common bus line to form a

storage capacitor between the data electrode and the common bus line; a second insulator over

the data electrode; and a common electrode over the second insulator.

The patent recites in claim 3 the data electrode conductively coupled to the common bus

line through a hole in the first and second insulators.

The patent recites in claim 7 the data bus lines including one of a Mo metal layer,

Mo/Al/Mo triple metal layers, or Cr/Al/Cr triple metal layers.

The patent recites in claim 9 the alignment layer including of polyimide or polyamide, or

polyvinylcinnamate or polysiloxane based materials.

The use of a black matrix (commonly disposed in non-displaying regions) is common and

known in the art for advantages such as high contrast and resolution. Therefore, it would have

been obvious to one of ordinary skill in the art to employ a black matrix for advantages such as

high contrast and resolution.

Contact Information

4. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Toan Ton whose telephone number is (703) 305-3489. Any

inquiry of a general nature or relating to the status of this application or proceeding should be

directed to the receptionist whose telephone number is (703) 308-0956.

August 28, 2003

TOANTON

REMARY EXAMINER

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